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Alves

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[54] **CHALK LINE HOLSTER**

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[**] Term: **14 Years**

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[52] U.S. Cl. **D3/228**

[58] Field of Search D3/228, 219, 222,
D3/223; 224/242, 253, 271, 272, 904, 908,
252; D10/61, 128, 72, 69; 33/369, 370,
371, 372, 373, 391, 392, 393, 394, 414

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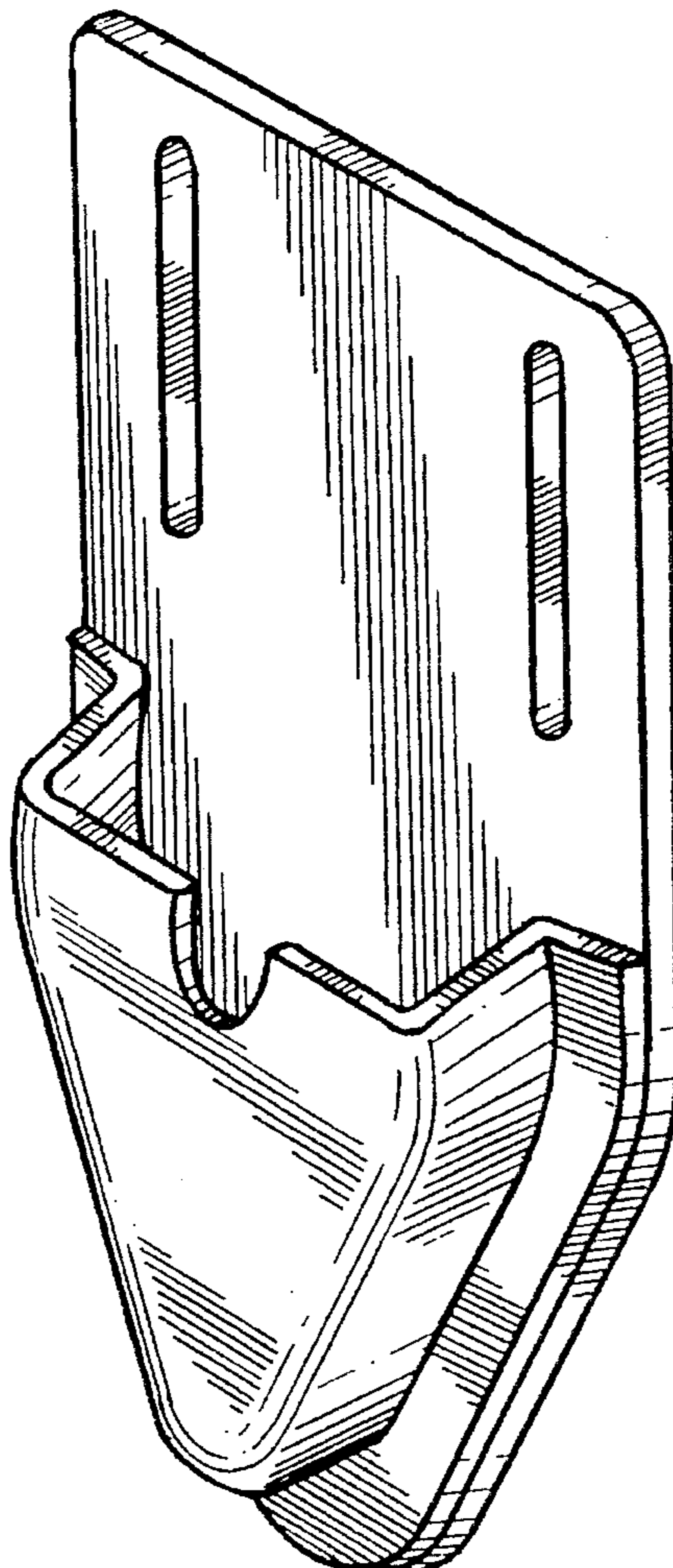
[57] CLAIM

The ornamental design for a chalk line holster, as shown and described.

DESCRIPTION

FIG. 1 is a front, top and side perspective view of the chalk line holster embodying the design of the present invention; FIG. 2 is a front elevational view thereof; FIG. 3 is a rear elevational view thereof; FIG. 4 is a side elevational view thereof, the side opposite being a mirror image of the side shown in FIG. 4; FIG. 5 is a top plan view thereof; and, FIG. 6 is a bottom plan view thereof.

1 Claim, 3 Drawing Sheets



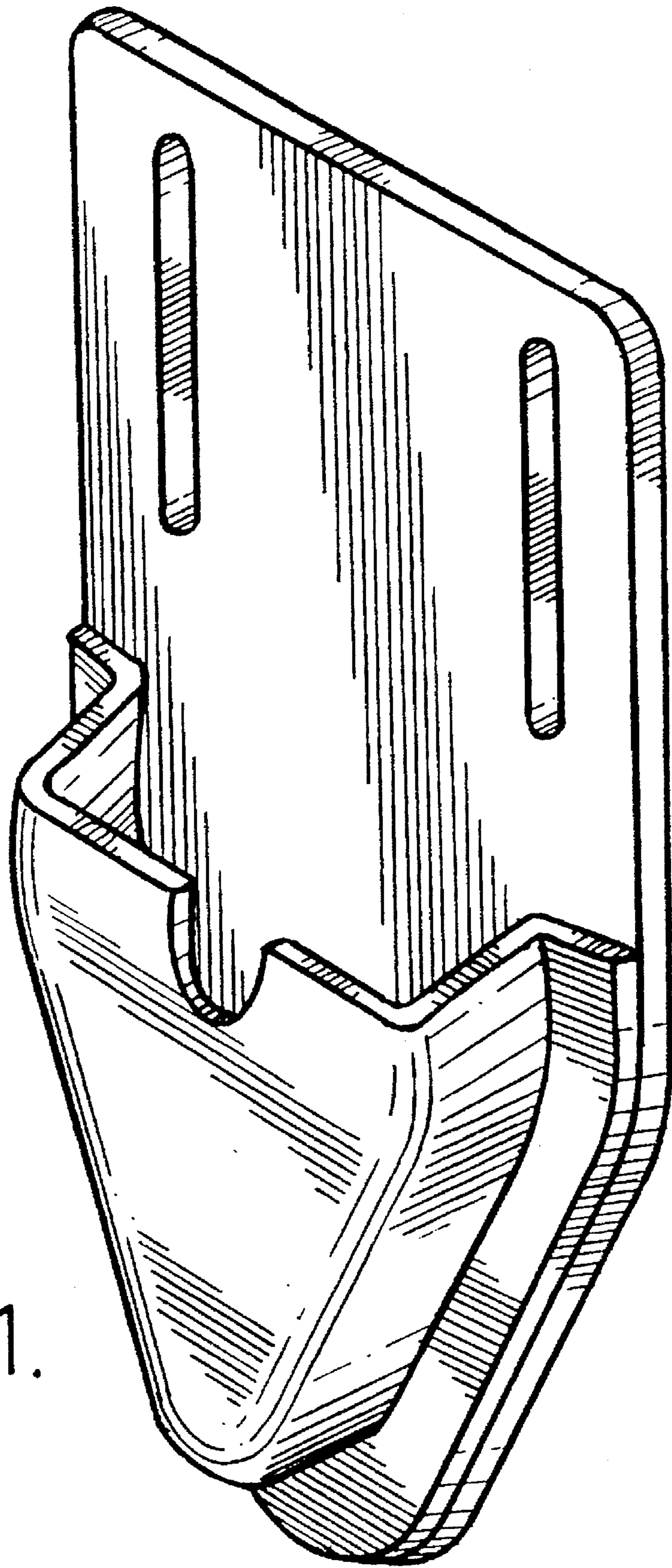


FIG.1.

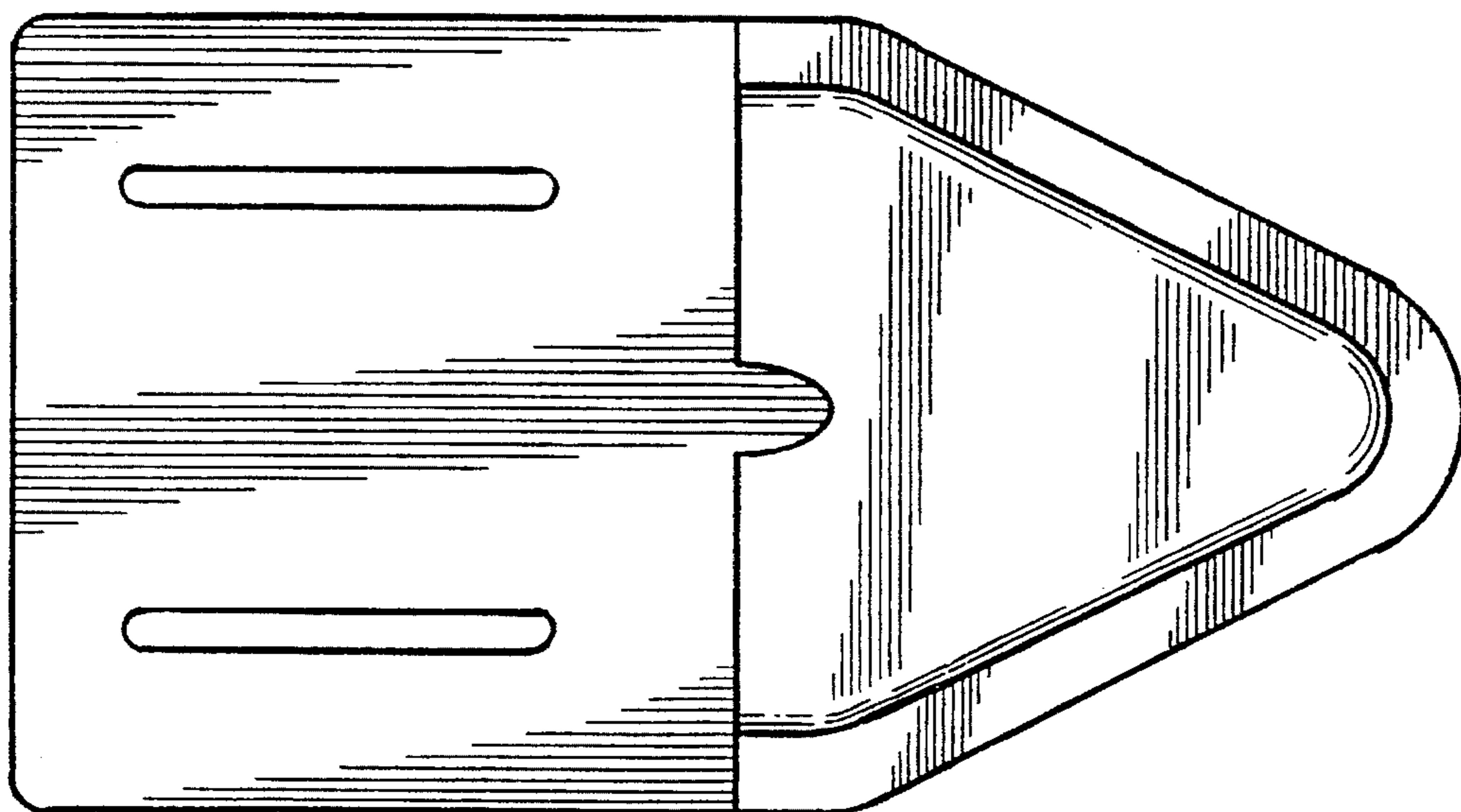


FIG. 2.

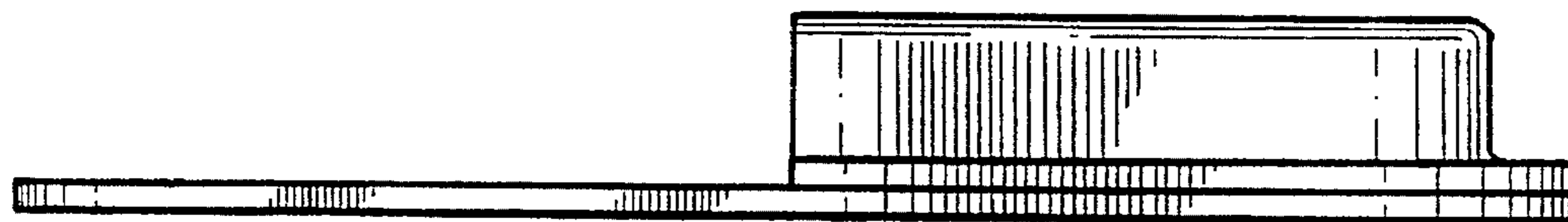


FIG. 4.

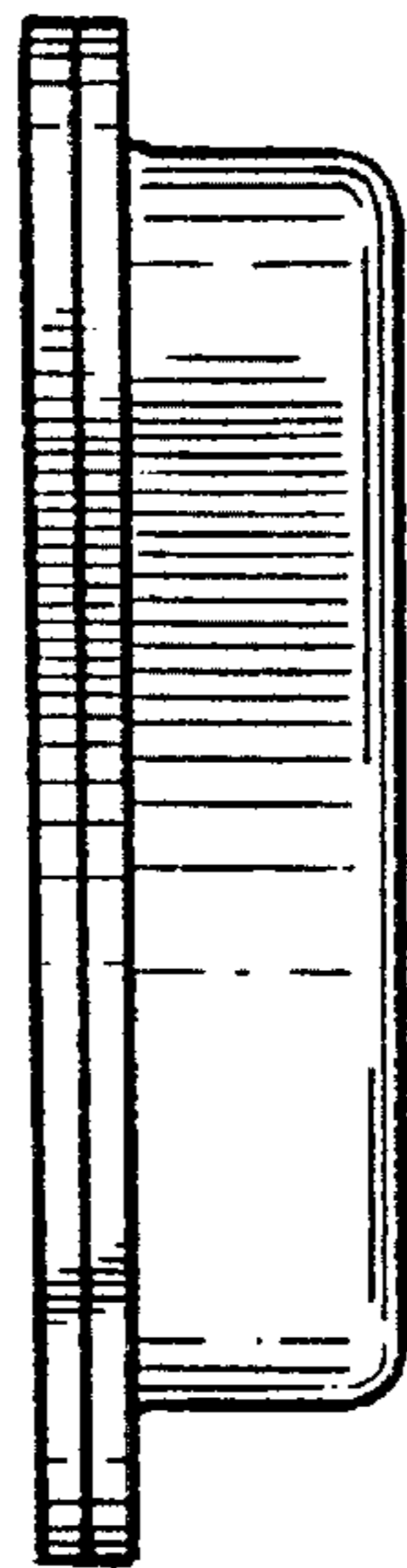


FIG. 6.

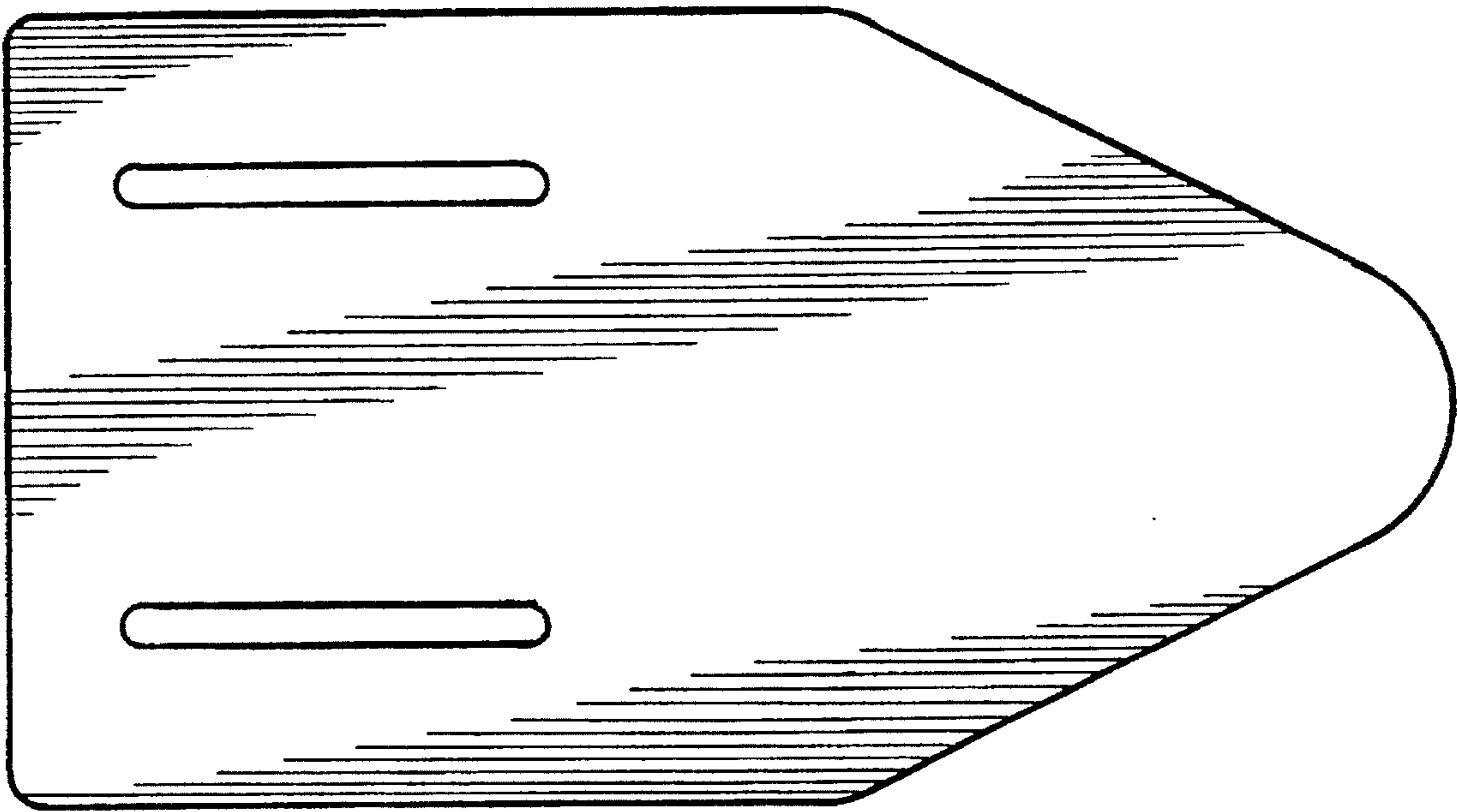


FIG. 3.

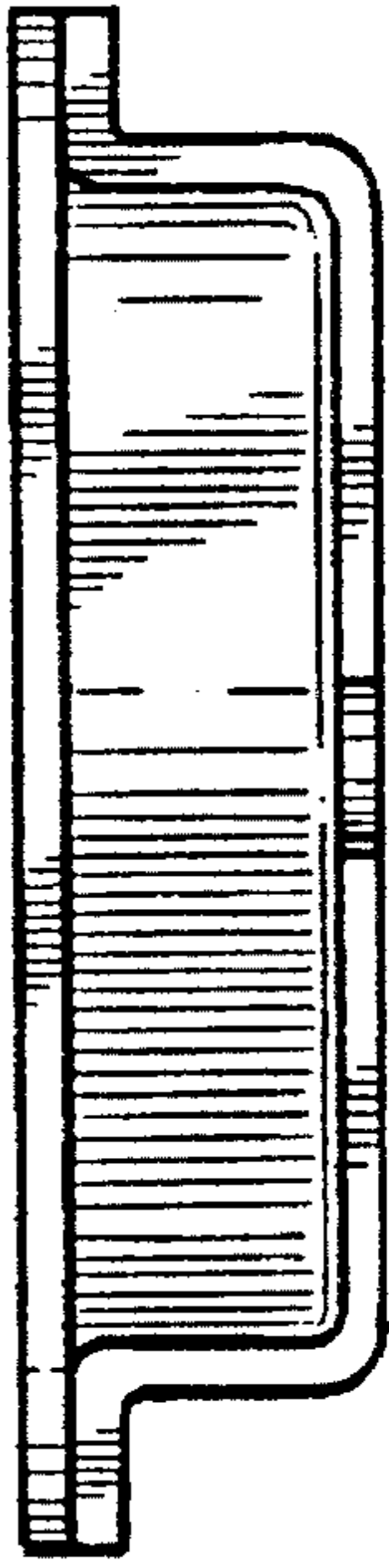


FIG. 5.